

CRYOGENICS OPERATIONS 2008

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JT60 SA : Baking Scenarios Studies

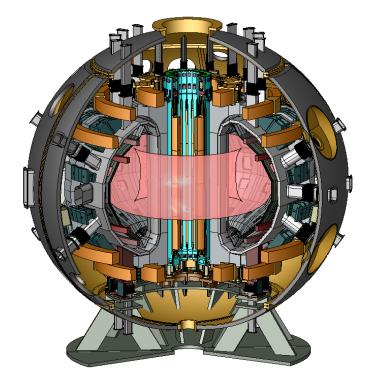
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V. Lamaison, 22th-26th September 2008

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Outline



- Baking for what ?
- Impact on the cryogenic system
- JT60 SA Baking
 - » Baking conditions and constraints
 - » Plasma Operation State
 - » 3 scenarios : baking and associated cool down
- Conclusion

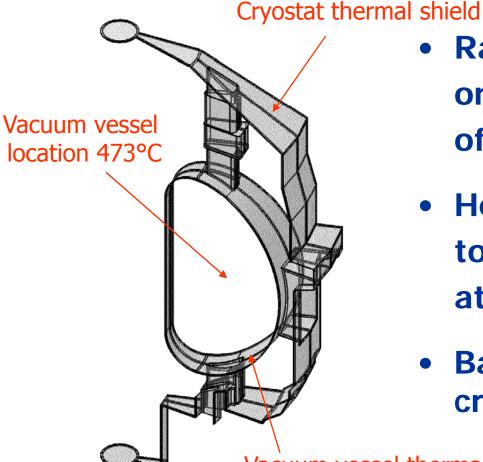


- Plasma facing surfaces conditioning is an aspect of plasma operation necessary to obtain very low impurity release conditions that are essential for tokamak plasma operation in general and high fusion performance operation
- Baking of the vacuum vessel is one of the techniques used
- Baking is efficient in removing water, volatile hydrocarbons and hydrogen
- Vacuum vessel temperature is led and maintained to around 200°C (473K) during several days



Impact on the cryogenic system

1/ 36 JT60 thermal shields



- Radiation heat loads on thermal shields of vacuum vessel increase
- Helium mass flow to maintain thermal shields at 80K increases
- Baking can be sizing for the cryogenic system

Vacuum vessel thermal shield



JT60 SA Baking

- Baking conditions :
 - » Vacuum vessel temperature = 313 to 473K, heat speed =10K/h
 - » Tinlet thermal shields = 80K
 - » Toutlet thermal shields \leq 140K
 - » Magnets temperature \leq 70K
 - » 5 days of baking every 3 weeks
- Baking constraints :
 - » baking must be a «non-sizing» operation state for the cryogenic system compared to the Plasma Operation State (POS)
 - » POS fixes maximum helium mass flow
- 3 scenarios :
 - » baking phase
 - » associated cool down phase



- Heat loads at 4.3K = 6.23kW
 Helium loops through a thermal buffer
 He mass flow = 460g/s
- HTS current leads He Mass flow (50K-300K) = 24g/s
- Heat loads at 80K = 32kW

(Radiation heat loads on thermal shields = 22.8kW)

He Mass flow (80K-100K) = 300g/s

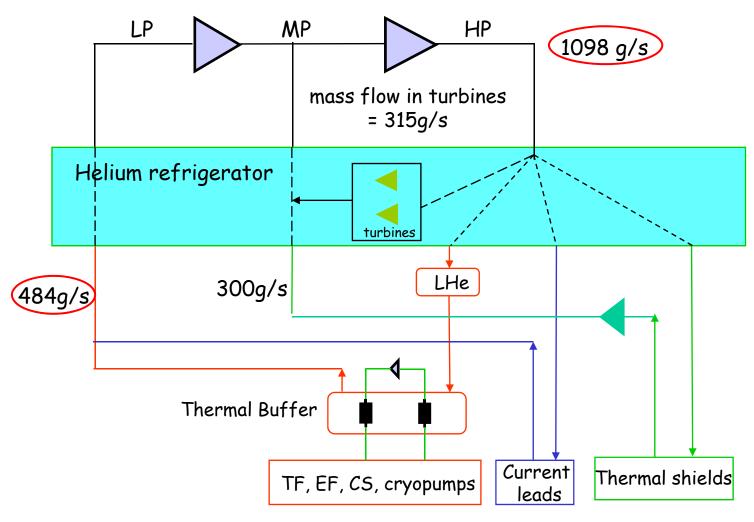
Return to low pressure

Return
 to middle pressure



JT60 SA Plasma Operation State

• Scheme of the cryoplant





• Baking : thermal conditions

- Vacuum vessel temperature = 313 to 473K, heat speed = 10K/h
- Average temperature of thermal shields = 100K, Tinlet = 80K, Toutlet = 120K, heat speed = 1K/h Radiation heat loads on thermal shields = 117kW
- Magnets temperature = 4.5K
 Helium loops through thermal buffer in operation

Heat loads at 4.5K = 4.32kW

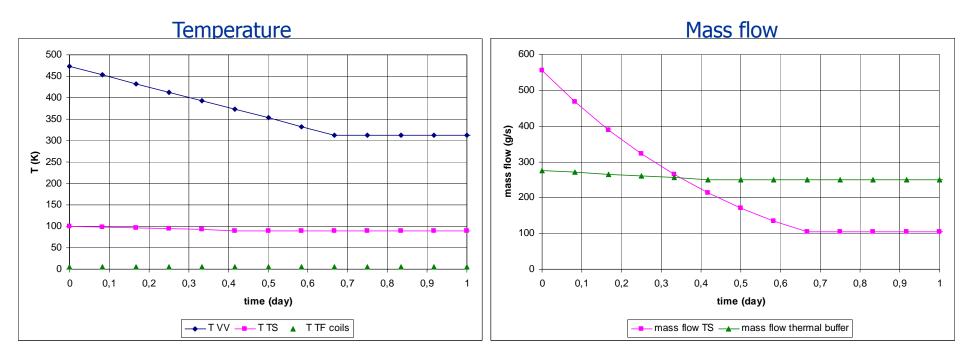
Helium loops in operation Mass flow = 280g/s Heat loads at 80K = 124kW Radiation heat loads on TS = 117kW Mass flow = 602g/s

 1^{st} stage of compression = 280g/s 2^{nd} stage of compression = 280+602+220 = 1102g/s



• Cool down after 5 days of baking

- > Cool down speed of vacuum vessel = 10K/h from 473K to 313K
- > Cool down speed of thermal shields = 1K/h from 100K to 90K



Thermal conditions of POS mode are restored after 0.7 day of cool down



• Baking : thermal conditions

- Vacuum vessel temperature = 313 to 473K, heat speed = 10K/h
- Average temperature of thermal shields = 105K, Tinlet = 80K, Toutlet = 130K, heat speed = 1K/h Radiation heat loads on thermal shields = 117kW
- Magnets temperature = 4.5K
 Helium loops through thermal buffer in operation

Heat loads at 4.5K = 4.57kW

Helium loops in operation Mass flow = 292g/s Heat loads at 80K = 124kW Radiation heat loads on TS = 117kW Mass flow = 490g/s

 1^{st} stage of compression = 292g/s 2^{nd} stage of compression = 292+490+220 = 1002g/s



• Baking : thermal conditions

- Vacuum vessel temperature = 313 to 473K, heat speed = 10K/h
- Average temperature of thermal shields = 105K, Tinlet = 80K, Toutlet = 130K, heat speed = 1K/h Radiation heat loads on thermal shields = 117kW
- Magnets temperature free Helium loops stopped

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Heat loads at 4.5K = 0kW Mass flow = 0g/s Heat loads at 80K = 124kW Radiation heat loads on TS = 117kW Mass flow = 490g/s

 1^{st} stage of compression stopped 2^{nd} stage of compression = 490g/s



Simulation

Baking

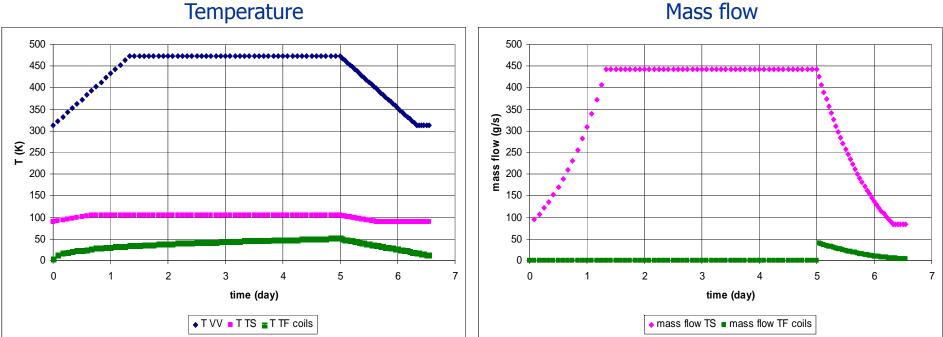
 \succ Vacuum vessel temperature increases from 313 to 473K with a heat speed = 10K/h

> Warm-up speed of thermal shields = 1K/h from 90K to 105K

Cool down after 5 days of baking

- > Cool down speed of vacuum vessel = 10K/h
- \succ Cool down speed of thermal shields and TF coils = 1K/h
- > Cool down of TF coils is performed by helium flow at high pressure





Temperature

- After 5 days of baking, TF coils reach 50K
- Thermal conditions of POS mode are restored after 2 days of cool down



Comparison of the 3 scenarios

- To compare the different scenarios, it is necessary to calculate theoretical electrical power for baking phase and associated cool down
- Low pressure is fixed at 1bar, middle pressure at 5bars and high pressure at 18bars

	Baking (5 days)	Associated Cool Down	TOTAL	DURATION
	kW.h	kW.h	kW.h	day
Scenario 1	66650	7255	73905	5+0.7=5.7
Scenario 2	63234	7093	70327	5+0.7=5.7
Scenario 3	21748	8434	30182	5+2=7

To combine electrical consumption and availability of the machine, the <u>scenario 3</u> remains the most efficient.